

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L14	386	UENISHI-K UENISHI-KAZUYA UENISHI-KAZUYA-C-O-FUGI-PHOTO UENISHI-KAZUYA-C-O-FUJI-PHOTO UENISHI-KAZUYA-FUJI-PHOTO-FILMAOAI-T AOA-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-FSATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:02
L15	6334	(photoacid acid) near generator	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:03
L16	497471	resist photoresist	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:03
L17	8050	cholic lithocholic cholate lithocholate deoxycholic	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:03
L18	1219	(\$10adamantyl \$10adamantane) near5 (acrylate methacrylate)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:03
L19	27	(US-20010038969-\$ or US-20010044070-\$ or US-20020015913-\$ or US-20020051933-\$ or US-20020102491-\$ or US-20020168581-\$ or US-20030013038-\$ or US-20030031950-\$ or US-20030039918-\$ or US-20030054286-\$ or US-20030138727-\$ or US-20030180659-\$).did. or (US-5879857-\$ or US-6159656-\$ or US-6280897-\$ or US-6280898-\$ or US-6383713-\$ or US-6479211-\$ or US-6492091-\$ or US-6517994-\$ or US-6548220-\$ or US-6579659-\$ or US-6593058-\$ or US-6596458-\$ or US-6602646-\$ or US-6692884-\$ or US-6703183-\$).did.	US-PGPUB; USPAT	OR	ON	2005/06/04 12:03
L20	19	14 and 15 and 16 and 17 and 18	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:04
L21	14	20 not 19	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:04
L22	16	((oligo oligomer) near5 (cholate deoxycholate lithocholate)) not (oligomer same ((dissolution adj suppressing adj agent) (dissolution-suppressing adj agent)))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:26
L23	44	((UENISHI-K UENISHI-KAZUYA UENISHI-KAZUYA-C-O-FUGI-PHOTO UENISHI-KAZUYA-C-O-FUJI-PHOTO UENISHI-KAZUYA-FUJI-PHOTO-FILMAOAI-T AOA-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-FSATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO) and (resist photoresist )) and ((photoacid acid) near generat\$4 ) ) and lactone	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:26
L24	27	19 AND (HYDROXYADAMANTYL (METHACRYLATE ACRYLATE))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:55

L25	19	20 AND (HYDROXYADAMANTYL (METHACRYLATE ACRYLATE))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/06/04 13:53
L26	26	24 AND ((PROPYLENE ADJ GLYCOL MONOMETHYL ADJ ETHER) LACTATE KETONE)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:56
L27	91	MOMOTA-M MOMOTA-MAKOTO MOMOTA-MAKOTO-C-O-FUJI-PHOTO-F NAKAO-HAJIME	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/06/04 13:50
L28	2	jp-2001142212-\$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/06/04 13:50
L29	35	HYDROXYADAMANTYL adj (METHACRYLATE ACRYLATE)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/06/04 13:58
L30	1	27 and 29 and lactone	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/06/04 13:53
L31	353645	HYDROXYADAMANTYL (METHACRYLATE ACRYLATE)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/06/04 13:58
L32	18	27 and 31	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/06/04 13:58
L33	2	"20010044070"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/06/04 14:09
L34	2	("6835527").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2005/06/04 14:20
L35	85	phenacylsulfonium	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/06/04 16:49
L36	3	32 AND 35	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/06/04 16:21
S1	939	(\$10adamantyl \$10adamantane) near5 (acrylate methacrylate)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/05/05 08:48

S2	441921	resist photoresist	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/05/05 08:48
S3	19048	(photoacid acid) near generat\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/05/05 08:48
S4	476	S1 and S2 and S3	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/05/05 08:49
S5	368	S4 and ("430"/\$.ccls.)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/05/05 08:49
S6	164	S4 and ("430"/\$.ccls.)	USPAT	OR	ON	2004/05/05 08:58
S12	1	wo-200010916-\$.did.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/05/05 08:59
S13	2	("6383713").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/05/05 10:01
S14	16913	(photoacid acid) near generat\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/10/20 15:18
S15	42593	lactone	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:03
S16	1166	dissolution adj inhibitor) (dissolution adj2 suppressing) (dissoluton	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2003/09/30 11:20
S17	5779	cholic lithocholic cholate lithocholate deoxycholic	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:03
S18	115	((photoacid acid) near generat\$4) and lactone and (dissolution adj inhibitor) (dissolution adj2 suppressing) (dissoluton)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2003/09/29 18:38
S19	767	(\$10adamantyl \$10adamantane) near5 (acrylate methacrylate)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:03
S20	51	((((photoacid acid) near generat\$4) and lactone and (dissolution adj inhibitor) (dissolution adj2 suppressing) (dissoluton) ) and ((\$10adamantyl \$10adamantane) near5 (acrylate methacrylate)))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2003/09/29 18:39
S21	413066	resist photoresist	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:03
S22	51	(((((photoacid acid) near generat\$4) and lactone and (dissolution adj inhibitor) (dissolution adj2 suppressing) (dissoluton) ) and ((\$10adamantyl \$10adamantane) near5 (acrylate methacrylate)))) and (resist photoresist )	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2003/09/30 11:21

S24	42622	lactone	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2003/09/30 11:20
S25	16928	(photoacid acid) near generat\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:03
S26	110551	dissolution adj inhibitor) (dissolution adj2 suppressing) (dissolution) (solubility adj inhibit\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2003/09/30 11:20
S27	769	(\$10adamantyl \$10adamantane) near5 (acrylate methacrylate)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2003/09/30 11:21
S28	413419	resist photoresist	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/05/05 08:48
S29	52	(((photoacid acid) near generat\$4) and lactone and (dissolution adj inhibitor) (dissolution adj2 suppressing) (dissoluton) ) and ((\$10adamantyl \$10adamantane) near5 (acrylate methacrylate))) and (resist photoresist )	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/05/05 08:49
S37	1	oligomer same ((dissolution adj suppressing adj agent) (dissolution-suppressing adj agent))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2003/09/30 13:02
S38	16	(oligo oligomer) near5 (cholate deoxycholate lithocholate)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2003/09/30 13:03
S39	15	((oligo oligomer) near5 (cholate deoxycholate lithocholate)) not (oligomer same ((dissolution adj suppressing adj agent) (dissolution-suppressing adj agent)))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/04 12:26
S40	5	("5738972"   "5786131"   "5866299"   "6136500"   "6280900"   "2001/0033993").PN.	USPAT	OR	ON	2004/05/03 17:34
S41	4	"6492091".URPN.	USPAT	OR	ON	2004/05/03 17:36
S42	6	("5968713"   "6013416"   "6068512"   "6200725"   "6280898"   "6492091"   "2001/0003640").PN.	USPAT	OR	ON	2004/05/03 17:48
S43	3	"6579659".URPN.	USPAT	OR	ON	2004/05/03 17:59
S44	5	("5738972"   "5786131"   "5866299"   "6136500"   "6280900"   "2001/0033993").PN.	USPAT	OR	ON	2004/05/03 18:00
S45	4	"6492091".URPN.	USPAT	OR	ON	2004/05/03 18:00
S46	9	("4018767"   "4166915"   "4188219"   "5185143"   "5541344"   "5811462"   "5910392"   "6008306"   "6057083").PN.	USPAT	OR	ON	2005/06/04 13:45
S47	13	"6280898".URPN.	USPAT	OR	ON	2004/05/04 18:05
S48	2	((("6280898") or ("6383713"))).PN.	USPAT	OR	OFF	2004/10/18 18:07
S49	2	((("6280898") or ("6383713"))).PN.	USPAT	OR	OFF	2004/10/27 18:13

S50	418	((((((UENISHI-K UENISHI-KAZUYA UENISHI-KAZUYA-C-O-FUGI-PHOTO UENISHI-KAZUYA-C-O-FUJI-PHOTO UENISHI-KAZUYA-FUJI-PHOTO-FILMAOI-T AOAI-TOSHIAKI AOAI-TOSHIAKI-C-O-FUGI-PHOTO-F AOAI-TOSHIAKI-C-O-FUJI-PHOTO-FSATO-KENICHIRO SATO-KENICHIRO-C-O-FUJI-PHOTO) and (resist photoresist )) and ((photoacid acid) near generat\$4 ) ) and lactone ) not ((((((photoacid acid) near generat\$4) and lactone and (dissolution adj inhibitor) (dissolution adj2 suppressing) (dissoluton) ) and ((\$10adamantyl \$10adamantane) near5 (acrylate methacrylate))) and (resist photoresist ) )) and (dissolution adj inhibitor) (dissolution adj2 suppressing) (dissolution) (solubility adj inhibit\$4)) and ((\$10adamantyl \$10adamantane) near5 (acrylate methacrylate) )	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/10/27 19:43
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